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SEMICONDUCTOR MEASUREMENT SYSTEM HAVING MONOCHROMATOR AND OPERATING METHOD THEREOF

Abstract

Provided is a semiconductor measurement system including a laser configured to output a light having multiple wavelengths, a broadband spectrometer configured to receive the light and output monochromatic light having a single wavelength, a measurement device configured to obtain physical information of a sample based on the monochromatic light, and a computing device configured to inspect or measure the sample based on the obtained physical information, wherein the broadband spectrometer is further configured to remove polarization dependence of the light based on a wavelength and a polarization separating/combining device.

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Background/Summary

CROSS-REFERENCE TO RELATED APPLICATION(S)

[0001] This application claims priority to Korean Patent Application No. 10-2024-0022065, filed on Feb. 15, 2024, in the Korean Intellectual Property Office, the disclosure of which is incorporated by reference herein in its entirety.

BACKGROUND

1. Field

[0002] Embodiments of the present disclosure relate to a physical unclonable function circuit, a security circuit having the same, and a method of operating the same.

2. Description of Related Art

[0003] In semiconductor manufacturing processes, optical measurement instruments such as Spectroscopic Reflectometry (SR) and Spectroscopic Ellipsometry (SE) may be widely used. The optical measurement instruments mentioned above may more precisely measure dimensions (Dimension) such as film thickness of semiconductor circuit structures formed on silicon substrates and optical constants such as refractive index. These optical measurement instruments are also referred to as Optical Critical Dimension (OCD) measurement devices, which compare measurement results with simulation results using models of semiconductor circuit structures and derive dimensions or optical constants of constituent materials by fitting. Broadband spectrometers generally refer to scientific instruments that measure the absorption, reflection, or transmission of light within a wide spectrum range. Broadband spectrometers measure the intensity of light and generate spectrum data across various wavelength ranges. Broadband spectrometers generally consist of spectroscopic components that disperse light into various wavelengths and detectors.

SUMMARY

[0004] One or more embodiments provide a semiconductor measurement system eliminating wavelength/polarization dependence and an operating method thereof.

[0005] According to an aspect of one or more embodiments, there is provided a semiconductor measurement system including a monochromator including a first wavelength control device configured to separate a collimated beam including multiple wavelengths into a plurality of wavelength bands, a second wavelength control device configured to receive diffracted light beams corresponding to the plurality of wavelength bands and output one of the diffracted light beams as a collimated beam of a single wavelength, first polarization optics configured to separate respective separated light beams corresponding to the plurality of wavelength bands into two polarization beams orthogonal to each other and match polarization directions of the separated polarization beams, second polarization optics configured to output the diffracted light beams corresponding to the plurality of wavelength bands by separating each of the diffracted light beams having the matched polarization direction into two polarization beams orthogonal to each other and combining the separated polarization beams, and a multi-grating mount including diffraction gratings configured to output the diffracted light beams having the matched polarization direction by diffracting each of the polarization beams having the matched polarization direction output from the first polarization optics.

[0006] According to another aspect of one or more embodiments, there is provided a semiconductor measurement system including a monochromator including an incident light unit configured to receive incident light of multiple wavelengths, a light splitting unit configured to split

the incident light of the multiple wavelengths into light beams corresponding to a plurality of wavelength bands, and an emitted light unit configured to output one of the split light beams as emitted light of a single wavelength, wherein the light splitting unit includes a wavelength control device configured to output separated collimated beams into areas respectively corresponding to the plurality of wavelength bands or combine diffracted light beams corresponding to the plurality of wavelength bands, polarization optics configured to separate each of the collimated beams into orthogonal polarization beams, match polarization directions of the separated polarization beams, and output diffracted light beams of the same wavelength in different optical paths as diffracted light beams having polarization beams orthogonal to each other, and a multi-grating mount having a plurality of diffraction gratings respectively corresponding to the plurality of wavelength bands, the plurality of diffraction gratings being configured to diffract the collimated beams having the matched polarization direction.

[0007] According to still another aspect of one or more embodiments, there is provided a semiconductor measurement system including a laser configured to output a light having multiple wavelengths, a broadband spectrometer configured to receive the light and output monochromatic light having a single wavelength, a measurement device configured to obtain physical information of a sample based on the monochromatic light, and a computing device configured to inspect or measure the sample based on the obtained physical information, wherein the broadband spectrometer is further configured to remove polarization dependence of the light based on a wavelength and a polarization separating/combining device.

[0008] According to further still another aspect of one or more embodiments, there is provided an operating method of a monochromator, the operating method including selecting a polarization direction corresponding to monochromatic light of a single wavelength, receiving a light of multiple wavelengths, and outputting the monochromatic light using a multi-grating mount including diffraction gratings configured to diffract collimated beams in the polarization direction, wherein the monochromatic light is output by splitting the light of the multiple wavelengths based on a wavelength and a polarization separating/combining device.

Description

BRIEF DESCRIPTION OF DRAWINGS

[0009] The above and other aspects, features, and advantages of embodiments will be more clearly understood from the following detailed description, taken in conjunction with the accompanying drawings, in which:

[0010] FIG. 1 is a diagram illustrating a monochromator according to one or more embodiments;

[0011] FIG. 2 is a diagram illustrating a monochromator according to one or more embodiments;

[0012] FIG. 3 is a diagram illustrating an optical polarization instrument according to one or more embodiments;

[0013] FIG. 4 is a diagram illustrating a broadband spectrometer according to one or more embodiments;

[0014] FIG. 5 is a diagram illustrating an operation of a polarizing beam splitter according to one or more embodiments;

[0015] FIG. 6 is a diagram illustrating an operation of a monochromator according to one or more embodiments;

[0016] FIG. 7 is a diagram illustrating a monochromator according to one or more embodiments;

[0017] FIG. 8 is a diagram illustrating optimal diffraction efficiency according to a polarization state of a monochromator according to one or more embodiments;

[0018] FIG. 9 is a diagram illustrating that a full-wavelength scanning time is reduced by avoiding physical replacement of a diffraction grating in a monochromator according to one or more

embodiments; and

[0019] FIG. 10 is a diagram illustrating a semiconductor measurement system according to one or more embodiments.

DETAILED DESCRIPTION

[0020] Hereinafter, embodiments will be described in detail using the drawings. Embodiments described herein are example embodiments, and thus, the disclosure is not limited thereto.

[0021] It will be understood that, although the terms first, second, third, fourth, etc. may be used herein to describe various elements, components, regions, layers and/or sections (collectively “elements”), these elements should not be limited by these terms. These terms are only used to distinguish one element from another element. Thus, a first element described in this description section may be termed a second element or vice versa in the claim section without departing from the teachings of the disclosure.

[0022] It will be understood that when an element or layer is referred to as being “over,” “above,” “on,” “below,” “under,” “beneath,” “connected to” or “coupled to” another element or layer, it may be directly over, above, on, below, under, beneath, connected or coupled to the other element or layer or intervening elements or layers may be present. In contrast, when an element is referred to as being “directly over,” “directly above,” “directly on,” “directly below,” “directly under,” “directly beneath,” “directly connected to” or “directly coupled to” another element or layer, there are no intervening elements or layers present.

[0023] As used herein, an expression “at least one of” preceding a list of elements modifies the entire list of the elements and does not modify the individual elements of the list. For example, an expression, “at least one of a, b, and c” should be understood as including only a, only b, only c, both a and b, both a and c, both b and c, or all of a, b, and c.

[0024] In accordance with one or more embodiments, a semiconductor measurement system with a monochromator and operating method thereof may separate only the desired wavelengths using diffracted light from a diffraction grating for broadband optical input and may output the separated monochromatic light.

[0025] A monochromator using a diffraction grating may separate light into various wavelengths and selectively extract one specific wavelength. Monochromators primarily receive light of various wavelengths from a source such as a blackbody or a light source. The incident angle of the input light incident on the diffraction grating may be adjusted using the monochromator. By adjusting the incident angle, the monochromator causes light of a specific wavelength to diffract at a specific angle on the diffraction grating. The diffraction grating separates light into different wavelengths using this method. The surface of the diffraction grating may include high-density fine grooves or spacing. When light passes through these gratings, light of various wavelengths may be diffracted at different angles. The fine spacing and patterns of the diffraction grating determine the size of the separated wavelengths. Light passing through the diffraction grating is separated at various angles. A detector detects where light of a specific wavelength reaches and converts that information into a signal. Slits selectively allow only light of a specific wavelength to pass through. By adjusting the size and position of the slits, light of the desired wavelength may be selectively extracted. When light of the selected wavelength passes through the slits, the light may be transmitted to the detector, resulting in obtaining a spectrum or a light signal of a specific wavelength.

[0026] According to one or more embodiments, a monochromator may include diffraction gratings for each wavelength band, a multi-grating mount, a polarizing optical element, and a wavelength control module. The monochromator according to one or more embodiments may increase the grating bandwidth and the number of gratings for broadband monochromator operation. The monochromator according to one or more embodiments may be implemented by separating diffracted light by a diffraction grating for broadband optical input.

[0027] The intensity of outgoing light may be determined by the diffraction efficiency (DE) of the grating. The diffraction efficiency (DE) of each grating may have wavelength and polarization

dependencies depending on the medium and shape of the reflecting surface of the grating (such as groove density, blazed angle, etc.). Due to constraints of grating bandwidth, broadband monochromators use multiple gratings corresponding to each wavelength band. Generally, broadband monochromators use a turret-type grating mount. The broadband monochromator according to one or more embodiments may expand the bandwidth of each grating by adding a polarizing optical element to a broadband monochromator. Additionally, the broadband monochromator according to one or more embodiments may enable continuous wavelength scanning without additional time delay during grating replacement by utilizing a wavelength control module and a multi-grating module.

[0028] FIG. 1 is a diagram illustrating a monochromator **10** according to one or more embodiments. Referring to FIG. 1, the monochromator **10** may include an incident light unit **11**, a light splitting unit **12**, and an emitted light unit **13**.

[0029] The incident light unit **11** may receive light having a plurality of wavelengths through an optical fiber. The incident light unit **11** may convert light from the incident optical fiber into a collimated beam.

[0030] The light splitting unit **12** may be implemented to output incident light as monochromatic light using a diffraction grating. The light splitting unit **12** may include a wavelength control device **12-1**, polarization optics **12-2**, and a multi-grating mount **12-3**.

[0031] The wavelength control device **12-1** may be implemented to output separated collimated beams into spaces (areas) respectively corresponding to a plurality of wavelength bands or to combine diffracted light beams corresponding to the plurality of wavelength bands. In one or more embodiments, the wavelength control device **12-1** may include a wavelength separating device that separates the collimated beams into the spaces (areas) corresponding to the plurality of wavelength bands, and a wavelength combining device that combines the diffracted light beams corresponding to the plurality of wavelength bands. The wavelength control device **12-1** may be implemented to separate broadband incident light into a plurality of wavelength bands.

[0032] The polarization optics **12-2** may be implemented to respectively separate the collimated beams into orthogonal polarization beams, match polarization directions of the separated polarization beams, and output diffracted light beams of the same wavelength in different optical paths as diffracted light beams having polarization beams orthogonal to each other. The polarization optics **12-2** may separate the light separated into each wavelength band into two orthogonal polarization beams (P-polarization and S-polarization). Thereafter, the polarization optics **12-2** may adjust the light for each polarization to have a favorable polarization (P-polarization or S-polarization) in a grating.

[0033] The multi-grating mount **12-3** may be implemented to include a plurality of diffraction gratings that respectively correspond to the plurality of wavelength bands and diffract the collimated beams having the matched polarization direction. In one or more embodiments, the multi-grating mount **12-3** may further include a rotation stage that rotates each of the plurality of diffraction gratings. In addition, the light beams separated while passing through the wavelength control device **12-1** and the polarization optics **12-2** may be incident on the grating, and then the diffracted light may be transmitted as emitted light while again passing through the polarization optics **12-2** and the wavelength control device **12-1**. At this time, each diffraction grating may be located on one plane, for example, on the multi-grating mount **12-3**. Each diffraction grating may be placed to be on several planes with different angle of incidences (AOIs) while sharing the same axis of rotation. Scanning of all the wavelength bands may be possible by rotating the multi-grating mount **12-3** without the need for additional grating switching.

[0034] The emitted light unit **13** may output light having the selected wavelength through the optical fiber. Here, the output light may be light of 250 nm to 1100 nm, and a wavelength band that is greater than or less than 250 nm to 1100 nm according to a type of the diffraction grating and the optical fiber. The emitted light unit **13** may couple emitted collimated beam to an emitted optical

fiber.

[0035] A general monochromator uses a plurality of gratings each having a wide bandwidth to respond to a broadband. When increasing a bandwidth of the grating, the polarization dependence of diffraction efficiency increases. This is an inappropriate characteristic as an optical critical dimension (OCD) light source, which measures a polarization change. In addition, a monochromator may use a turret mount to operate on the plurality of gratings, which may cause an additional switch time delay of a grating when changing a wavelength band used, which may cause a decrease in measurement throughput.

[0036] The monochromator **10** according to one or more embodiments adds the wavelength control device **12-1** and the optical polarization instrument **12-2**, thereby eliminating the polarization dependence of incident polarization (or optimizing polarization of incident light). In addition, the monochromator **10** according to one or more embodiments may eliminate the grating switching time delay using the multi-grating mount **12-3**.

[0037] FIG. **2** is a diagram illustrating a monochromator **100** according to one or more embodiments. Referring to FIG. **2**, the monochromator **100** may include an incident light unit **110**, a wavelength separator **120**, polarization optics **131**, **132**, **133**, **134**, **135**, and **136**, a multi-grating mount **140**, a wavelength combiner **150**, and an emitted light unit **160**. Here, the wavelength separator **120**, the polarization optics **131** to **136**, the diffraction grating mount **140**, and the wavelength combiner **150** may be collectively referred to as a light splitting unit. The light splitting unit may output multi-wavelength collimated beam that has passed through the incident light unit **110** as short-wavelength collimated beam. When the polarization dependence of a diffraction grating and incident light is relatively small or the transmittance of an optical polarization instrument is relatively low according to a wavelength band, the optical polarization instrument may be omitted.

[0038] The incident light unit **110** may include a light source **111**, an optical fiber **112**, and a collimator **113**. The light source **111** may be implemented to generate broadband incident light having multiple wavelengths. The optical fiber **112** may receive the broadband incident light. The collimator **113** may output the light output from the optical fiber **112** to the wavelength separator **120** as collimated beam of multiple wavelengths.

[0039] The wavelength separator **120** may be implemented to separate the multi-wavelength incident light into two or more light beams having different wavelength bands. In one or more embodiments, the wavelength separator **120** may output separated light beams into first spaces (areas) corresponding to the plurality of wavelength bands using first bandpass filters **121** and **122** and first mirrors **123** and **124**. The wavelength separator **120** may include the first bandpass filters **121** and **122** and the first mirrors **123** and **124**. In one or more embodiments, each of the first mirrors **123** and **124** may be a dichroic mirror. When N or more wavelength separating devices are combined, N+1 spatially separated light beams having different wavelength bands may be formed. The light reflected from each wavelength separating device may be adjusted so that a traveling direction (+z-axis) is parallel to transmitted light by mirror reflection.

[0040] The light of each wavelength band spatially separated through the wavelength separator **120** may be light having the same polarization while passing through each of the corresponding polarization optics **131**, **132**, and **133**. The light may be separated into two orthogonal polarization components (P-polarization or S-polarization) by the polarization optics **131**, **132**, and **133**. Each of the separated light beams may be transmitted and reflected. A direction of the reflected light may be adjusted to be parallel with the traveling direction (+z-axis) of light by mirror reflection.

[0041] The light passing through the wavelength separator **120** and the polarization optics **131**, **132**, and **133** may be ultimately formed as 2 and N+1 spatially separated collimated beams of the same polarization in a horizontal (y-axis) direction and a vertical (x-axis) direction, respectively. In one or more embodiments, when using the three polarization optics **131**, **132**, and **133** for three wavelength bands of ultraviolet (UV), visible (VIS), and infrared (IR) bands, a total of $2 \times (2 + 1) = 6$

collimated beams proceed.

[0042] Each of the separated light beams passing through the wavelength separator **120** and the polarization optics **131**, **132**, and **133** is incident on a multi-grating including a grating corresponding to each wavelength band. To obtain the maximum diffraction efficiency for each grating, the grating incident polarization may be optimized by changing an angle of a polarization controller of the optical polarization instrument. In a multi-grating unit, multiple gratings **141**, **142**, and **143** may be mounted in parallel on the multi-grating mount **140** fixed on one rotation stage **144**. When the gratings **141**, **142**, and **143** mounted in parallel are configured with the same pitch and different blaze angles, monochromatic light corresponding to each grating wavelength band may be continuously dispersed according to the rotation of the rotation stage **144**. The pitch refers to a distance between grating lines. The distance determines the characteristics of diffraction and affects the dispersion and emission of light of various wavelengths. The blaze angle reflects and disperses light of a specific wavelength as efficiently as possible. The blaze angle varies depending on a wavelength and affects the wavelength resolution and dispersion characteristics of a spectrometer. When mounting the multiple gratings **141**, **142**, and **143** on the multi-grating mount **140** to have different AOIs while sharing a rotation axis, the monochromatic light corresponding to each grating wavelength band may be continuously dispersed according to the rotation even in a combination of gratings with different pitches.

[0043] The wavelength combiner **150** may be implemented to combine different monochromatic light beams. In one or more embodiments, the wavelength combiner **150** may output diffracted light beams in second spaces (areas) corresponding to the plurality of wavelength bands as a collimated beam of a single wavelength using second bandpass filters **151** and **152** and second mirrors **153** and **154**. The wavelength combiner **150** may include the second bandpass filters **151** and **152** and the second mirrors **153** and **154**. In one or more embodiments, each of the second mirrors **153** and **154** may be a dichroic mirror. A total of $2(N+1)$ light beams incident and diffracted from each grating may pass through the polarization optics **134**, **135**, and **136** corresponding to the emitted light unit **160** and the wavelength combiner **150** in the reverse order of incidence and then be transmitted to the emitted light unit **160**.

[0044] The emitted light unit **160** may include an optical fiber **162** and a collimator **163**. The optical fiber **162** may output monochromatic light (collimated beam) of the collimator **163** to an external device. The collimator **163** may receive collimated beam of a single wavelength from the wavelength combiner **150**. Due to light beams of different wavelength bands having different diffraction angles, only a specific wavelength component may pass through the polarization optics **134**, **135**, and **136** and the wavelength combiner **150** and then finally reach the optical fiber **162** through the emitted light unit **160**.

[0045] FIG. **3** is a diagram illustrating an optical polarization instrument according to one or more embodiments. The optical polarization instrument may include a polarizing beam splitter or a polarization combiner. Here, the polarizing beam splitter may be implemented to separate collimated beams into orthogonal polarization beams and match polarization directions of the separated polarization beams. The polarization combiner may be implemented to output diffracted light beams of the same wavelength in different optical paths as diffracted light beams having polarization beams orthogonal to each other. The optical polarization instrument **131** shown in FIG. **3** may include a polarizing beam splitter PBS, a mirror M, and a polarization controller HWP. The polarizing beam splitter PBS may include a polarization beam splitter. The polarization controller may include a half-wave plate. The polarization controller may match a polarization direction of transmitted light of the polarizing beam splitter PBS with a polarization direction of reflected light reflected from the mirror M. In one or more embodiments, the polarization direction may be manually determined. In other embodiments, the polarization direction may be automatically changed according to a wavelength.

[0046] FIG. **4** is a diagram illustrating a broadband spectrometer **200** according to one or more

embodiments. Referring to FIG. 4, the broadband spectrometer **200** may include a first wavelength control device **211**, a second wavelength control device **212**, first polarization optics **221**, second polarization optics **222**, and a multi-grating mount **230**.

[0047] Each of the first wavelength control device **211** and the second wavelength control device **212** may include bandpass filters BPF1 and BPF2 and mirrors M1 and M2. In one or more embodiments, the first wavelength control device **211** may output separated light beams to first spaces (areas) corresponding to a plurality of wavelength bands using the at least one first bandpass filter BPF1/BPF2 and the at least one first mirror M1/M2. In one or more embodiments, the second wavelength control device **212** may output diffracted light beams of second spaces (areas) corresponding to the plurality of wavelength bands as collimated beams of a single wavelength using the at least one second bandpass filter BPF1/BPF2 and the at least one second mirror M1/M2.

[0048] Each of the first polarization optics **221** and second polarization optics **222** may include three polarization optics. In one or more embodiments, each of the first polarization optics **221** may include a polarizing beam splitter that outputs transmitted light and reflected light by separating collimated beam into polarization beams orthogonal to each other, a mirror that reflects the reflected light, a first polarization adjustor that adjusts polarization of the reflected light of the mirror, and a second polarization adjustor that adjusts polarization of the transmitted light of the polarizing beam splitter. In one or more embodiments, each of the second polarization optics **222** may include a first polarization adjustor that adjusts polarization of first diffracted light of a diffraction grating, a second polarization adjustor that adjusts polarization of second diffracted light of the diffraction grating, a mirror that reflects the adjusted polarization of the first polarization controller, and a polarization combiner that combines the polarization reflected from the mirror with the adjusted polarization of the second polarization controller.

[0049] A multi-wavelength light source incident through an optical fiber may spatially separate wavelength/polarization through wavelength separating/combining devices **211/212** and polarization separating/combining devices **221/222** the first and second wavelength control devices **211** and **212** and the first and second polarization optics **221** and **222**. Such separated light beams may be incident on the corresponding gratings of the multi-grating mount **230**. At this time, an angle of the polarization control device HWP of the polarizing beam splitter **221** may be rotated so that the separated light beams may be incident on the gratings as polarization having higher light efficiency according to an incident wavelength. The multi-grating mount **230** may be rotated in a plane vertical direction, and light may be split into the desired diffraction wavelength according to each angle. Such split light may pass through the polarization combiner **222** and the wavelength combining device **212** corresponding to emitted light and then be emitted to the optical fiber of an output unit.

[0050] FIG. 5 is a diagram illustrating an operation of a polarizing beam splitter according to one or more embodiments. Referring to FIG. 5, each of first and second polarization optics **221-1** and **222-1** may include the polarizing beam splitter PBS, the mirror M, and first and second polarization control devices HWP1 and HWP2. Light may be optimally separated according to the dependence of a corresponding grating **241** using the polarization control device HWP1 or HWP2.

[0051] In one or more embodiments, the first optical polarization instrument **221-1** may include the polarizing beam splitter PBS that outputs transmitted light and reflected light by separating collimated beam into polarization beams orthogonal to each other, the mirror M that reflects the reflected light, the first polarization adjustor HWP1 that adjusts polarization of the reflected light of the mirror M, and the second polarization adjustor HWP2 that adjusts polarization of the transmitted light of the polarizing beam splitter PBS.

[0052] In one or more embodiments, the second optical polarization instrument **222-2** may include the first polarization adjustor HWP1 that adjusts polarization of first diffracted light of the diffraction grating **241**, the second polarization adjustor HWP2 that adjusts polarization of second diffracted light of the diffraction grating **241**, the mirror M that reflects the adjusted polarization of

the first polarization adjustor HWP1, and a polarization combiner that combines the polarization reflected from the mirror M with the adjusted polarization of the second polarization adjustor HWP2.

[0053] A broadband spectrometer adds the number of gratings to minimize the wavelength and polarization dependence of the grating efficiency. However, the addition of the number of gratings causes an increase in the driving time and an increase in the size of each of a grating mount and a driving unit. Also, the broadband spectrometer **200** according to one or more embodiments may facilitate an increase in the number of gratings without a relative increase in the system size. In addition, the broadband spectrometer **200** according to one or more embodiments may be implemented as an ultra-wideband spectrometer that covers the entire broadband range from ultraviolet to infrared.

[0054] FIG. **6** is a diagram illustrating an operation of the monochromator **100** according to one or more embodiments. Referring to FIG. **6**, the operation method of the monochromator **100** according to one or more embodiments is illustrated. The monochromator **100** may select the optimal polarization for output monochromatic light (operation **S110**). For example, with respect to polarization of the output monochromatic light that maximizes the grating efficiency, either P-polarization or S-polarization may be selected. Thereafter, broadband light may be received by the monochromator **100** through an optical fiber (operation **S120**). Thereafter, monochromatic light may be output using a multi-grating mount having diffraction gratings that diffract collimated beams in a polarization direction. The monochromatic light may be output by splitting a light source of multiple wavelengths using a wavelength and polarization separating/combining module (operation **S130**).

[0055] In one or more embodiments, the light source of multiple wavelengths may be separated into collimated beams corresponding to a plurality of wavelength bands, and the separated collimated beams may be output to spaces (areas) corresponding to the plurality of wavelength bands. In one or more embodiments, each of the separated collimated beams may be separated into orthogonal polarization beams, and the separated polarization beams may be adjusted in selected polarization directions. In one or more embodiments, the adjusted polarization beams may be diffracted in the corresponding diffraction gratings, and the diffracted polarization beams may be adjusted as different polarization beams. In one or more embodiments, the adjusted polarization beams may be combined by a polarization combiner.

[0056] FIG. **7** is a diagram illustrating a monochromator **300** according to one or more embodiments. Referring to FIG. **7**, the monochromator **300** may include an incident light unit **310**, a first wavelength and polarization separating/combining module **320**, a second wavelength and polarization separating/combining module **330**, a multi-grating unit **340**, and an emitted light unit **350**.

[0057] In one or more embodiments, the first wavelength and polarization separating/combining module **320** may be implemented as the wavelength separator **120** and the polarization optics **131**, **132**, and **133** shown in FIG. **2**. In one or more embodiments, the second wavelength and polarization separating/combining module **330** may be implemented as the wavelength combiner **150** and the polarization optics **134**, **135**, and **136** shown in FIG. **2**.

[0058] The monochromator **300** according to one or more embodiments may increase a grating bandwidth by minimizing the polarization dependence of a multi-wavelength grating (i.e., by optimizing polarization of incident light).

[0059] FIG. **8** is a diagram illustrating optimal diffraction efficiency (DE) according to a polarization state of a monochromator according to one or more embodiments. As shown in FIG. **8**, by comparing the graphs of S-polarization, P-polarization, and un-polarization, in the case of a multi-wavelength grating, DE dependence on wavelength and incident polarization is relatively high. The monochromator according to one or more embodiments may allow light of polarization having optimal efficiency for each wavelength to be incident on a grating using an optical

polarization instrument, thereby minimizing polarization dependence (effect). Accordingly, a monochromator with relatively high efficiency may be implemented without increasing the number of gratings.

[0060] FIG. **9** is a diagram illustrating that a full-wavelength scanning time is reduced by avoiding physical replacement of a diffraction grating in a monochromator according to one or more embodiments. In the case of the existing multi-wavelength monochromator, turret-type mounts are used to simultaneously use several gratings due to the limitation of a diffraction wavelength band of a grating. When using a triangular turret with three gratings mounted to implement a broadband (250 nm to 1100 nm) monochromator, a rotation angle of at least 240° is required to scan the entire wavelength band. Also, in the case of the monochromator according to one or more embodiments, all gratings may be placed on a multi-grating mount having the same rotation axis, and thus, no additional rotation for grating use is required.

[0061] The monochromator according to one or more embodiments has a driving angle of 1/7 (in the case of ~33°, pitch 1200 gr/mm) compared to the existing monochromator. Considering a stabilization time for each grating rotation, the time required to scan the entire wavelength band may be reduced to at least 1/7 or less compared to the existing turret type.

[0062] FIG. **10** is a diagram illustrating a semiconductor measurement system **1000** according to one or more embodiments. Referring to FIG. **10**, the semiconductor measurement system **1000** may include a light source **1100**, a broadband spectrometer **1200**, a measurement device **1800**, and a computing device **1900**.

[0063] The light source **1100** may be implemented to generate a broadband light source. The light source **1100** may be implemented as a SC laser. The light source **1100** is connected to a single mode fiber SFB. Light generated by the light source **1100** is emitted from a single mode fiber tangential SFBT through the single mode fiber SFB. The single mode fiber tangential SFBT may also serve as an incidence slit of the broadband spectrometer **1200**. As described above, the light may include laser light emitted from a fiber, and the incidence slit may include a tangential of the fiber. When using high-output white light using plasma as a broadband light source, a connection optical fiber becomes a multi-mode fiber MFB.

[0064] The broadband spectrometer **1200** disperses the incident light and emits light of a target wavelength from an emission slit as emitted light. The light emitted from the broadband spectrometer **1200** is incident on the multi-mode fiber MFB. In addition, a multimode fiber tangential MFBT, which is an entrance to the multi-mode fiber MFB, may also serve as an emission slit of the broadband spectrometer **1200**. The split light incident on the multimode fiber tangential MFBT is incident on an optical system **1810** in the measurement device **1800** through the multi-mode fiber MFB. Also, the light is used for a necessary measurement or inspection. In addition, the broadband spectrometer **1200** may be implemented using the monochromator and the operating method thereof described with reference to FIGS. **1** to **9**.

[0065] The measurement device **1800** inspects or measures a sample **1890** using the light emitted from the broadband spectrometer **1200**. The sample **1890** is, for example, a semiconductor such as a semiconductor substrate or semiconductor circuit. In addition, the sample **1890** may be a member other than the semiconductor. The measurement device **1800** includes the optical system **1810** and an image detector **1880**. The measurement device **1800** may further include a base, an isolator, an optical plate, a frame, a stage, and a wafer holder.

[0066] The optical system **1810** may be mounted on the frame, and the frame may be fixed to the optical plate. The optical plate may be placed on the base. The isolator may be disposed between the optical plate and the base. The stage may drive the wafer holder supporting the sample **1890**. The wafer holder holding the sample **1890** may be placed on the stage. The stage may be placed below the optical system **1810**. The measurement device **1800** captures an image of the sample **1890** with the image detector **1880** using the optical system **1810**. Accordingly, the measurement device **1800** inspects or measures physical information of the sample **1890**.

[0067] The computing device **1900** includes, for example, an information processing device, such as a computer **1910**. In addition to the computer **1910**, the computing device **1900** includes, for example, a digital micro mirror device (DMD) control unit **1920**, an image detection control unit **1930**, and a stage control unit **1940**. The DMD control unit **1920** controls an operation of a DMD. The image detection control unit **1930** controls an operation of the image detector **1880**. The stage control unit **1940** controls an operation of a stage **1860**.

[0068] The measurement device **1800** may inspect or measure the sample **1890** by independently using light including a plurality of wavelengths emitted from the broadband spectrometer **1200**. In addition, the measurement device **1800** may perform measurement.

[0069] The devices described above may be implemented as hardware components, software components, and/or a combination of hardware components and software components. For example, the devices and components described in the embodiment may be implemented using one or more general-purpose or special-purpose computers, such as a processor, a controller, an arithmetic logic unit (ALU), a digital signal processor, a microcomputer, a field programmable gate array (FPGA), a programmable logic unit (PLU), a microprocessor, or any other device capable of executing and responding to instructions. The computing device **1900** may run an operating system (OS) and one or more software applications running on the OS. In addition, the computing device **1900** may access, store, manipulate, process, and generate data in response to the execution of software. For ease of understanding, it is described that one computing device **1900** is used, but those skilled in the art may be known that the computing device **1900** may include a plurality of processing elements or a plurality of types of processing elements. For example, the computing device **1900** may include a plurality of processors or one processor and one controller. In addition, other processing configurations, such as a parallel processor, are possible.

[0070] Software may include a computer program, code, instructions, or a combination of one or more of these, and may configure the computing device **1900** to operate as desired, or may independently or collectively instruct the computing device **1900**. Software and/or data may be embodied in any type of machine, a component, a physical device, virtual equipment, computer storage medium, or a device so as to be interpreted by the computing device **1900** or provide commands or data to the computing device **1900**. Software may be distributed over computer systems connected over a network and stored or executed in a distributed manner. Software and data may be stored on one or more computer-readable recording media.

[0071] Due to increased structural complexity (miniaturization, three-dimensional (3D) integration), ensuring measurement integrity of existing Optical Critical Dimension (OCD) is challenging. In this context, one or more embodiments may be applied to next-generation OCD (CSI, Continuous-angle spectroscopic information for ellipsometry) capable of capturing more information (Azimuth, AOI) at once compared to related OCD. This is achieved through the application of broadband (250~1100 nm) monochromator light source technology. Furthermore, since the wavelength range showing good OCD alignment may vary depending on the structure and properties of the pattern, a wider broadband light source is needed to selectively adapt to more diverse and fine patterns. The one or more embodiments enable inspection and measurement for all wavelength ranges within a single facility without replacing the light source or measurement equipment for wavelength range changes.

[0072] According to one or more embodiments, the semiconductor measurement system and an operating method thereof may eliminate the wavelength/polarization dependence of the output of monochromatic light used in semiconductor measurement.

[0073] According to one or more embodiments, the semiconductor measurement system and an operating method thereof may remove a grating switching time delay using a multi-grating mount when splitting light of multiple wavelengths.

[0074] While embodiments have been described with reference to the figures, it will be understood by those of ordinary skill in the art that various changes in form and details may be made therein

without departing from the spirit and scope as defined by the following claims and their equivalents.

Claims

1. A semiconductor measurement system comprising: a monochromator comprising: a first wavelength control device configured to separate a collimated beam comprising multiple wavelengths into a plurality of wavelength bands; a second wavelength control device configured to receive diffracted light beams corresponding to the plurality of wavelength bands and output one of the diffracted light beams as a collimated beam of a single wavelength; first polarization optics configured to separate respective separated light beams corresponding to the plurality of wavelength bands into two polarization beams orthogonal to each other and match polarization directions of the separated polarization beams; second polarization optics configured to output the diffracted light beams corresponding to the plurality of wavelength bands by separating each of the diffracted light beams having the matched polarization direction into two polarization beams orthogonal to each other and combining the separated polarization beams; and a multi-grating mount comprising diffraction gratings configured to output the diffracted light beams having the matched polarization direction by diffracting each of the polarization beams having the matched polarization direction output from the first polarization optics.
2. The semiconductor measurement system of claim 1, wherein the multi-grating mount is configured to be rotated to scan the plurality of wavelength bands.
3. The semiconductor measurement system of claim 1, wherein the monochromator further comprises: an optical fiber configured to receive broadband incident light; and an incident light unit comprising a collimator configured to output light output from the optical fiber to the first wavelength control device as the collimated beam of the multiple wavelengths.
4. The semiconductor measurement system of claim 1, wherein the monochromator further comprises: a collimator configured to receive the collimated beam of the single wavelength from the second wavelength control device; and an output light unit comprising an optical fiber configured to couple the collimated beam of the collimator.
5. The semiconductor measurement system of claim 1, wherein the first wavelength control device is configured to output the separated light beams to first areas corresponding to the plurality of wavelength bands based on at least one first bandpass filter and at least one first mirror, and wherein the second wavelength control device is configured to output the diffracted light beams in second areas corresponding to the plurality of wavelength bands as the collimated beam of the single wavelength based on at least one second bandpass filter and at least one second mirror.
6. The semiconductor measurement system of claim 5, wherein transmitted light of the at least one first bandpass filter and reflected light of the at least one first mirror are parallel to each other, and wherein transmitted light of the at least one second bandpass filter and reflected light of the at least one second mirror are parallel to each other.
7. The semiconductor measurement system of claim 1, wherein each of the first polarization optics comprises: a polarizing beam splitter configured to output transmitted light and reflected light by separating the collimated beam into polarization beams orthogonal to each other; a mirror configured to reflect the reflected light; a first polarization controller configured to adjust a polarization of the reflected light of the mirror; and a second polarization controller configured to adjust a polarization of the transmitted light of the polarizing beam splitter.
8. The semiconductor measurement system of claim 1, wherein each of the second polarization optics comprises: a first polarization controller configured to adjust a polarization of first diffracted light of the diffraction gratings; a second polarization controller configured to adjust a polarization of second diffracted light of the diffraction gratings; a mirror configured to reflect the adjusted polarization of the first polarization controller; and a polarization combiner configured to combine

the polarization reflected from the mirror with the adjusted polarization of the second polarization controller.

9. The semiconductor measurement system of claim 8, wherein the first polarization controller and the second polarization controller each comprise a half-wave plate (HWP).

10. The semiconductor measurement system of claim 1, wherein the multi-grating mount is configured to mount the diffraction gratings in parallel, and wherein a pitch of the diffraction gratings is equal to a distance between grating lines, and a blaze angle of each of the diffraction gratings are different from each other.

11. A semiconductor measurement system comprising: a monochromator comprising: an incident light unit configured to receive incident light of multiple wavelengths; a light splitting unit configured to split the incident light of the multiple wavelengths into light beams corresponding to a plurality of wavelength bands; and an emitted light unit configured to output one of the split light beams as emitted light of a single wavelength, wherein the light splitting unit comprises: a wavelength control device configured to output separated collimated beams into areas respectively corresponding to the plurality of wavelength bands or combine diffracted light beams corresponding to the plurality of wavelength bands; polarization optics configured to separate each of the collimated beams into orthogonal polarization beams, match polarization directions of the separated polarization beams, and output diffracted light beams of the same wavelength in different optical paths as diffracted light beams having polarization beams orthogonal to each other; and a multi-grating mount having a plurality of diffraction gratings respectively corresponding to the plurality of wavelength bands, the plurality of diffraction gratings being configured to diffract the collimated beams having the matched polarization direction.

12. The semiconductor measurement system of claim 11, wherein the wavelength control device comprises: a wavelength separating device configured to separate the collimated beams into the areas corresponding to the plurality of wavelength bands; and a wavelength combining device configured to combine the diffracted light beams corresponding to the plurality of wavelength bands.

13. The semiconductor measurement system of claim 11, wherein the polarization optics comprise: a polarizing beam splitter configured to separate each of the collimated beams into the orthogonal polarization beams and match the polarization directions of the separated polarization beams; and a polarization combiner configured to output the diffracted light beams having equal wavelength in the different optical paths as the diffracted light beams having the polarization beams orthogonal to each other.

14. The semiconductor measurement system of claim 13, wherein the polarization direction is determined based on the single wavelength.

15. The semiconductor measurement system of claim 11, wherein the multi-grating mount further comprises a rotation stage configured to rotate each of the plurality of diffraction gratings.

16. A semiconductor measurement system comprising: a laser configured to output a light having multiple wavelengths; a broadband spectrometer configured to receive the light and output monochromatic light having a single wavelength; a measurement device configured to obtain physical information of a sample based on the monochromatic light; and a computing device configured to inspect or measure the sample based on the obtained physical information, wherein the broadband spectrometer is further configured to remove polarization dependence of the light based on a wavelength and a polarization separating/combining device.

17. The semiconductor measurement system of claim 16, wherein the broadband spectrometer comprises: a wavelength control device configured to output separated collimated beams into areas respectively corresponding to a plurality of wavelength bands or combine diffracted light beams corresponding to the plurality of wavelength bands; polarization optics configured to separate each of the collimated beams into orthogonal polarization beams, match polarization directions of the separated polarization beams, and output diffracted light beams of the same wavelength in different

optical paths as diffracted light beams having polarization beams orthogonal to each other; and a multi-grating mount comprising a plurality of diffraction gratings respectively correspond to the plurality of wavelength bands, the plurality of diffraction gratings being configured to diffract the collimated beams having the matched polarization direction.

18. The semiconductor measurement system of claim 17, wherein each of the plurality of diffraction gratings is on one plane.

19. The semiconductor measurement system of claim 17, wherein an optical efficiency based on an incident wavelength among the orthogonal polarization beams is highest in the matched polarization direction.

20. The semiconductor measurement system of claim 17, wherein the multi-grating mount is configured to rotate at a driving angle less than or equal to 33° .

21-25. (canceled)
